

Amendments to the Claims:

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Currently Amended) A magneto-resistive device comprising:
a magneto-resistive layer formed on one surface side of a base and including a free layer; and
a single-layer film formed to be in contact with an effective region effectively involved in detection of magnetism in said magneto-resistive layer without overlapping with said effective region,
wherein said single-layer film is formed of an insulating material made of an oxide or a nitride including at least one element, the atomic weight of said at least one element being larger than that of silicon,
said single-layer film excludes a layer for applying a biasing magnetic field to said free layer,
said single-layer film is in contact with said effective region on at least one side of said effective region, and
~~said effective region excludes the layer for applying the biasing magnetic field to said free layer from the at least one side of said effective region~~
the layer for applying the biasing magnetic field to said free layer is not located on the at least one side of said effective region.
2. (Original) A magneto-resistive device according to claim 1, wherein said insulating material is at least one selected from a group consisting of TiO₂, MgO, Ta₂O₅ and WO₃.
3. (Currently Amended) A magneto-resistive device comprising:

a magneto-resistive layer formed on one surface side of a base and including a free layer; and

a composite-layer film formed to be in contact with an effective region effectively involved in detection of magnetism in said magneto-resistive layer without overlapping with said effective region,

wherein a layer in said composite-layer film being located closest to said base is formed of an insulating material made of an oxide or a nitride including at least one element, the atomic weight of said at least one element being larger than that of silicon,

said composite-layer film excludes a layer for applying a biasing magnetic field to said free layer,

said composite-layer film is in contact with said effective region on at least one side of said effective region, and

~~said effective region excludes the layer for applying the biasing magnetic field to said free layer from the at least one side of said effective region~~
the layer for applying the biasing magnetic field to said free layer is not located on the at least one side of said effective region.

4. (Original) A magneto-resistive device according to claim 3, wherein said insulating material is at least one selected from a group consisting of TiO_2 , MgO , Ta_2O_5 and WO_3 .

5. (Currently Amended) A magneto-resistive device comprising:
a magneto-resistive layer formed on one surface side of a base and including a free layer; and
a composite-layer film formed to be in contact with an effective region effectively involved in detection of magnetism in said magneto-resistive layer without overlapping with said effective region,

wherein a layer in said composite-layer film being located closest to said base is formed of an insulating material,

at least one layer in said composite-layer film except for said layer being located closest to said base is made of a predetermined material including at least one element, the atomic weight of said at least one element being larger than that of silicon,

said composite-layer film excludes a layer for applying a biasing magnetic field to said free layer,

said composite-layer film is in contact with said effective region on at least one side of said effective region, and

~~said effective region excludes the layer for applying the biasing magnetic field to said free layer from the least one side of said effective region~~the layer for applying the biasing magnetic field to said free layer is not located on the at least one side of said effective region.

6. (Original) A magneto-resistive device according to claim 5, wherein said predetermined material is at least one selected from a group consisting of P, Ti, V, Cr, Mn, Fe, Co, Ni, Cu, Zn, Ga, Ge, As, Zr, Nb, Mo, Tc, Ru, Rh, Pt, Ag, Cd, In, Sn, Sb, Hf, Ta, W, Re, Os, Ir, Au, Hg, Tl, Pb, Bi, and non-magnetic metals and non-magnetic semiconductors including any one or more of said elements.

7. (Original) A magneto-resistive device according to claim 5, wherein said predetermined material is at least one selected from a group consisting of TiO_2 , MgO , Ta_2O_5 and WO_3 .

8. (Original) A magneto-resistive device according to claim 1, wherein said effective region is a region in which a current flows in a direction substantially perpendicular to a film surface of said magneto-resistive layer in said magneto-resistive layer.

9. (Original) A magneto-resistive device according to claim 1, further comprising:

a non-magnetic metal layer having one or more layers formed on said magneto-resistive layer on the side opposite to said base;

wherein said non-magnetic metal layer is formed such that said non-magnetic layer substantially exactly overlaps with at least the layer in said magneto-resistive layer furthest away from said base.

10. (Original) A magneto-resistive device according to claim 1, wherein said magneto-resistive layer includes a tunnel barrier layer formed on one surface side of said free layer, a pinned layer formed on one surface side of said tunnel barrier layer opposite to said free layer, and a pin layer formed on one surface side of said pinned layer opposite to said tunnel barrier layer, and

said single-layer film is in contact with an end face of said tunnel barrier layer.

11. (Original) A magnetic head comprising:

a base; and

a magneto-resistive device according to claim 1, said magneto-resistive device being supported by said base.

12. (Original) A magnetic head according to claim 11, wherein said single-layer film is in contact with said effective region on at least one side of said effective region opposite to a magnetic recording medium.

13. (Original) A magnetic head comprising:

a base; and

a magneto-resistive device according to claim 2, said magneto-resistive device being supported by said base.

14. (Original) A magnetic head comprising:

a base; and

a magneto-resistive device according to claim 3, said magneto-resistive device being supported by said base.

15. (Original) A magnetic head comprising:

a base; and

a magneto-resistive device according to claim 4, said magneto-resistive device being supported by said base.

16. (Original) A magnetic head comprising:

a base; and

a magneto-resistive device according to claim 5, said magneto-resistive device being supported by said base.

17. (Original) A magnetic head comprising:

a base; and

a magneto-resistive device according to claim 6, said magneto-resistive device being supported by said base.

18. (Original) A magnetic head comprising:

a base; and

a magneto-resistive device according to claim 7, said magneto-resistive device being supported by said base.

19. (Original) A head suspension assembly comprising:

a magnetic head according to claim 11; and

a suspension for supporting said magnetic head mounted near a leading end thereof.

20. (Original) A magnetic disk apparatus comprising:

a head suspension assembly according to claim 19;

an arm for supporting said head suspension assembly; and

an actuator for moving said arm to position said magnetic head.

21. (Previously Presented) A magnetic head according to claim 14, wherein said composite-layer film is in contact with said effective region on at least one side of said effective region opposite to a magnetic recording medium.

22. (Previously Presented) A magnetic head according to claim 16, wherein said composite-layer film is in contact with said effective region on at least one side of said effective region opposite to a magnetic recording medium.

23. (New) A magneto-resistive device according to claim 1, wherein said single-layer film does not overlap with the layer for applying the biasing magnetic field to said free layer on the at least one side of said effective region.

24. (New) A magneto-resistive device according to claim 3, wherein said composite-layer film does not overlap with the layer for applying the biasing magnetic field to said free layer on the at least one side of said effective region.

25. (New) A magneto-resistive device according to claim 5, wherein said composite-layer film does not overlap with the layer for applying the biasing magnetic field to said free layer on the at least one side of said effective region.

26. (New) A magneto-resistive device comprising:
a magneto-resistive layer formed on one surface side of a base and including a free layer; and
a single-layer film formed to be in contact with an effective region effectively involved in detection of magnetism in said magneto-resistive layer without overlapping with said effective region,

wherein said single-layer film is formed of an insulating material made of an oxide or a nitride including at least one element, the atomic weight of said at least one element being larger than that of silicon,

said single-layer film excludes a layer for applying a biasing magnetic field to said free layer,

said single-layer film is in contact with said effective region on at least one side of said effective region, and

said single-layer film does not overlap with the layer for applying the biasing magnetic field to said free layer on the at least one side of said effective region.

27. (New) A magneto-resistive device comprising:

a magneto-resistive layer formed on one surface side of a base and including a free layer; and

a composite-layer film formed to be in contact with an effective region effectively involved in detection of magnetism in said magneto-resistive layer without overlapping with said effective region,

wherein a layer in said composite-layer film being located closest to said base is formed of an insulating material made of an oxide or a nitride including at least one element, the atomic weight of said at least one element being larger than that of silicon,

said composite-layer film excludes a layer for applying a biasing magnetic field to said free layer,

said composite-layer film is in contact with said effective region on at least one side of said effective region, and

said composite-layer film does not overlap with the layer for applying the biasing magnetic field to said free layer on the at least one side of said effective region.

28. (New) A magneto-resistive device comprising:

a magneto-resistive layer formed on one surface side of a base and including a free layer; and

a composite-layer film formed to be in contact with an effective region effectively involved in detection of magnetism in said magneto-resistive layer without overlapping with said effective region,

wherein a layer in said composite-layer film being located closest to said base is formed of an insulating material,

at least one layer in said composite-layer film except for said layer being located closest to said base is made of a predetermined material including at least one element, the atomic weight of said at least one element being larger than that of silicon,

said composite-layer film excludes a layer for applying a biasing magnetic field to said free layer,

said composite-layer film is in contact with said effective region on at least one side of said effective region, and

said composite-layer film does not overlap with the layer for applying the biasing magnetic field to said free layer on the at least one side of said effective region.